

## EAST Search History

## EAST Search History (Prior Art)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S155	102	flow\$1type near10 (ald or ale or alcvd or atomic near2 layer near2 (epitax \$5 or deposit\$5 or chemical near2 vapor near2 deposit \$5))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/03/24 15:00
S156	3	flow\$1type near10 (ald or ale or alcvd or atomic near2 layer near2 (epitax \$5 or deposit\$5 or chemical near2 vapor near2 deposit \$5)) and @py<"2002"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/03/24 15:01
S159	3	asm near10 "F-120" and @py<"2003"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/03/24 15:02
S158	2	flow\$1type near10 "F-120" and @py<"2003"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/03/24 15:02
S157	29	flow\$1type near10 "F-120"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/03/24 15:02
S161	7	asm near10 ald and @py<"2003"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/03/24 15:07
S160	1	asm near10 "F120" and @py<"2003"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/03/24 15:07

S163	40	(silicate or perovskite) near10 (ald or ale or alcvd or atomic near2 layer near2 (epitax \$5 or deposit\$5 or chemical near2 vapor near2 deposit \$5)) and @py<"2004"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/03/24 15:08
S162	3277	(silicate or silicon) near10 (ald or ale or alcvd or atomic near2 layer near2 (epitax\$5 or deposit \$5 or chemical near2 vapor near2 deposit\$5))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/03/24 15:08
S166	9	asm near15 ald and @py<"2003"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/03/24 15:12
S165	104	asm near15 ald	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/03/24 15:12
S164	2	asm near15 ald near15 (sio2 or "sio. sub.2" or silicon near2 (oxide or dioxide))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/03/24 15:12
S167	33	flow near5 (ald or ale or atomic near2 layer near2 (deposit \$4 or epitax\$5 or cvd)) and @py<"2003" and ("sio.sub.2" or silicon adj dioxide)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/03/24 18:53
S168	3	"4085430".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/03/24 18:55

S169	20	(ald or ale or atomic near2 layer near2 (deposit\$4 or epitax\$5 or cvd)) near15 ("sio.sub.2" or silicon adj dioxide) and @py<"2002"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/03/24 18:57
L1	112	(eva near2 tois or suvi near2 haukka or marko near2 tuominen).in.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/03/27 15:49
L2	368	(atomic near2 layer near2 (epitax\$6 or deposit\$6)) near15 ((binary or tertiary or ternary or mixed))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/03/27 15:50

### EAST Search History (Interference)

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